## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**Applicant(s):** Kwang Choe et al.

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Alexandria, VA 22313-1450

## RESPONSE UNDER 37 C.F.R. §1.116

Sir:

In response to the Final Rejection dated March 14, 2008, please enter the following remarks and amendments as a matter of record in the above-identified application.

Amendments to the Claims are reflected in the listing of claims, which begin on page 2 of this paper.

Remarks begin on page 6 of this paper.

## CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on May 14, 2008. Harry A. Hild Jr.

Dated: May 14, 2008